

East 8USPB USPT, JPO, WPID

L Number	Hits	Search Text	DB	Time stamp
1	2174010	etch\$ or patern\$ or remov\$	USPAT; US-PGPUB	2004/05/25 13:03
2	172	coherence?	USPAT; US-PGPUB	2004/05/25 13:03
3	244886	wave? or wavelength?	USPAT; US-PGPUB	2004/05/25 13:03
4	0	(etch\$ or patern\$ or remov\$) same coherence? same (wave? or wavelength?)	USPAT; US-PGPUB	2004/05/25 13:01
5	32	(etch\$ or patern\$ or remov\$) and coherence? and (wave? or wavelength?)	USPAT; US-PGPUB	2004/05/25 13:02
6	1592356	etch\$ or patern\$ or remov\$	JPO; DERWENT	2004/05/25 13:27
7	18	coherence?	JPO; DERWENT	2004/05/25 13:03
8	125336	wave? or wavelength?	JPO; DERWENT	2004/05/25 13:03
9	0	(etch\$ or patern\$ or remov\$) and coherence? and (wave? or wavelength?)	JPO; DERWENT	2004/05/25 13:04
10	42094	photoresist? or mask? or photomask? or resist?	JPO; DERWENT	2004/05/25 13:18
11	460090	absorb\$	JPO; DERWENT	2004/05/25 13:18
12	349	(etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$	JPO; DERWENT	2004/05/25 13:05
13	1809854	laser or light or reflect\$ or interfer\$	JPO; DERWENT	2004/05/25 13:19
14	140	((etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$) and (laser or light or reflect\$ or interfer\$)	JPO; DERWENT	2004/05/25 13:07
15	6093408	measur\$ or end\$ or stop or test\$ or determin\$ or detect\$	JPO; DERWENT	2004/05/25 13:19
16	3790251	control\$ or computer?	JPO; DERWENT	2004/05/25 13:23
17	1294383	analyz\$ or calculat\$ or determin\$	JPO; DERWENT	2004/05/25 13:24
18	78	((etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$) and ((measur\$ or end\$ or stop or test\$ or determin\$ or detect\$) or (control\$ or computer?) or (analyz\$ or calculat\$ or determin\$))	JPO; DERWENT	2004/05/25 13:08
19	26	((etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$) and (laser or light or reflect\$ or interfer\$)) and (((etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$) and ((measur\$ or end\$ or stop or test\$ or determin\$ or detect\$) or (control\$ or computer?) or (analyz\$ or calculat\$ or determin\$)))	JPO; DERWENT	2004/05/25 13:09
20	52	((etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$) and ((measur\$ or end\$ or stop or test\$ or determin\$ or detect\$) or (control\$ or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$) and (laser or light or reflect\$ or interfer\$)) and (((etch\$ or patern\$ or remov\$) and (photoresist? or mask? or photomask? or resist?) and absorb\$) and ((measur\$ or end\$ or stop or test\$ or determin\$ or detect\$) or (control\$ or computer?) or (analyz\$ or calculat\$ or determin\$))))	JPO; DERWENT	2004/05/25 13:13
21	125485	photoresist? or mask? or photomask? or resist?	USPAT; US-PGPUB	2004/05/25 13:18
22	582243	absorb\$	USPAT; US-PGPUB	2004/05/25 13:19
23	1769559	laser or light or reflect\$ or interfer\$	USPAT; US-PGPUB	2004/05/25 13:19

26	2723892	measur\$ or end??? or endpoint? or stop or test?? or testing?	USPAT;	2004/05/25 13:22
28	1109492	or determin\$ or detect\$ control???? or computer?	US-PGPUB	2004/05/25 13:23
29	2115194	analyz\$ or calculat\$ or determin\$	USPAT;	2004/05/25 13:24
30	32478	(etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)	US-PGPUB	2004/05/25 13:25
31	873	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$	USPAT;	2004/05/25 13:25
32	446	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))	US-PGPUB	2004/05/25 13:26
33	0	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.	JPO;	2004/05/25 13:28
34	73863	438.clas. or 216.clas.	DERWENT	2004/05/25 13:27
35	0	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (438.clas. or 216.clas.)	JPO;	2004/05/25 13:27
36	0	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) and (438.clas. or 216.clas.)	DERWENT	2004/05/25 13:28
37	169	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.	USPAT;	2004/05/25 13:56
38	277	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.)	US-PGPUB;	2004/05/25 13:57
39	2	((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.) and endpoint?	JPO;	2004/05/25 13:57
			DERWENT	

40	275	<p>(((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.)) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.)) and endpoint?)</p>	USPAT; US-PGPUB; JPO; DERWENT	2004/05/25 13:58
41	275	<p>(((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.)) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$).ti,ab.)) and endpoint?)</p>	USPAT; US-PGPUB; JPO; DERWENT	2004/05/25 13:58

42	19	<p> ((((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$.ti,ab.)) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) not (((etch\$ or patern\$ or remov\$) same (photoresist? or mask? or photomask? or resist?)) same absorb\$) same ((laser or light or reflect\$ or interfer\$) or (measur\$ or end??? or endpoint? or stop or test?? or testing? or determin\$ or detect\$) or (control???? or computer?) or (analyz\$ or calculat\$ or determin\$))) and (etch\$ or patern\$ or remov\$.ti,ab.)) and endpoint?)) and (profilom\$ or ellipsom\$ or elipsomet\$) </p>	USPAT; US-PGPUB; JPO; DERWENT	2004/05/25 13:58
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